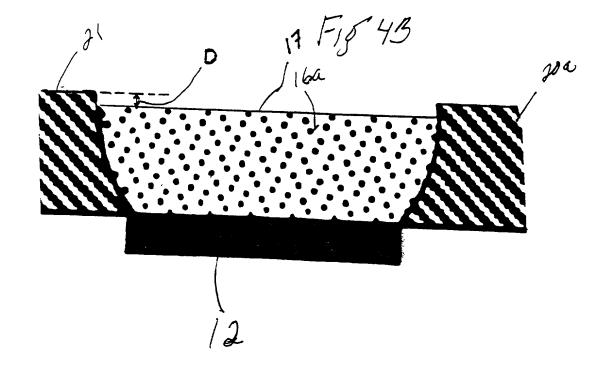


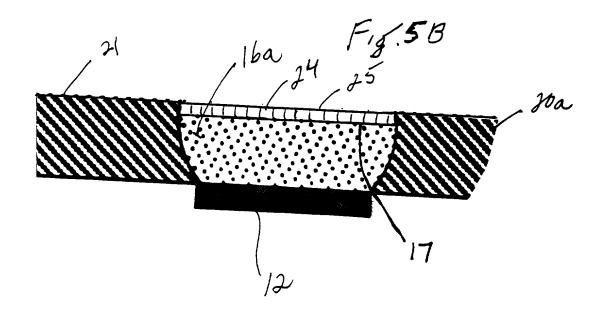
Rebump: shown with optional barrier layer and lower melting point second solder bumping

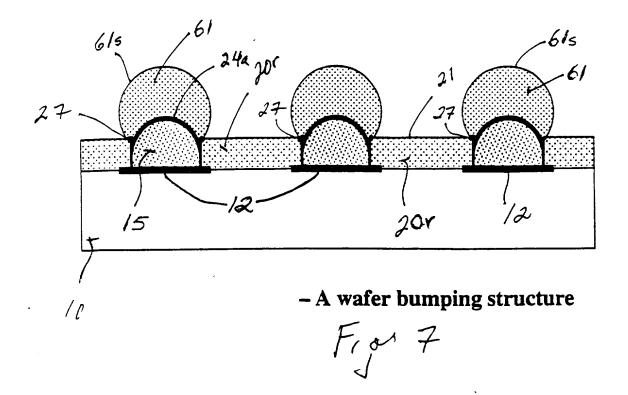
12

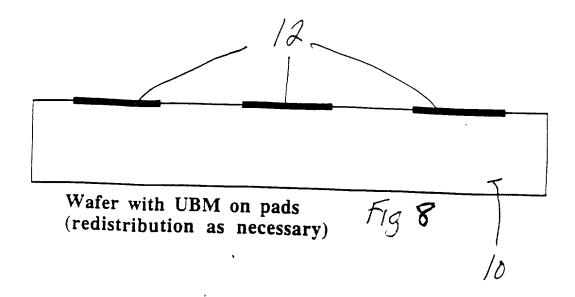
20a

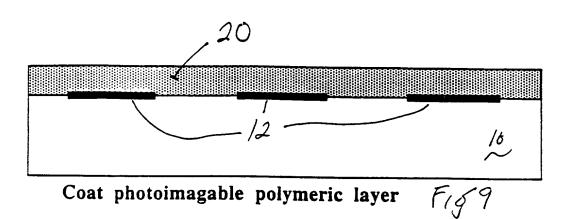
Fig. 6

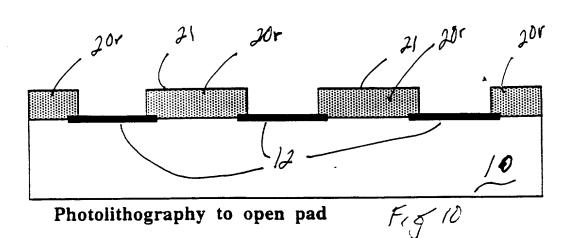


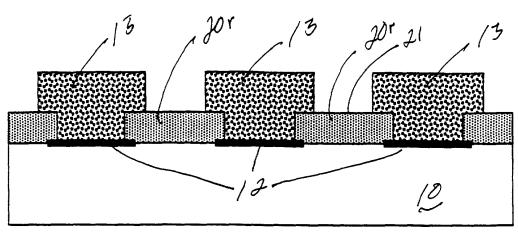






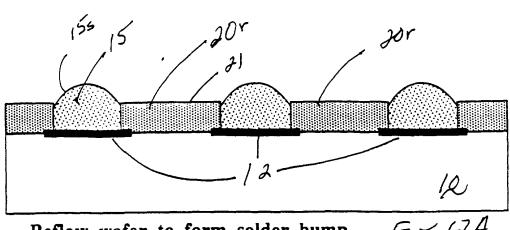






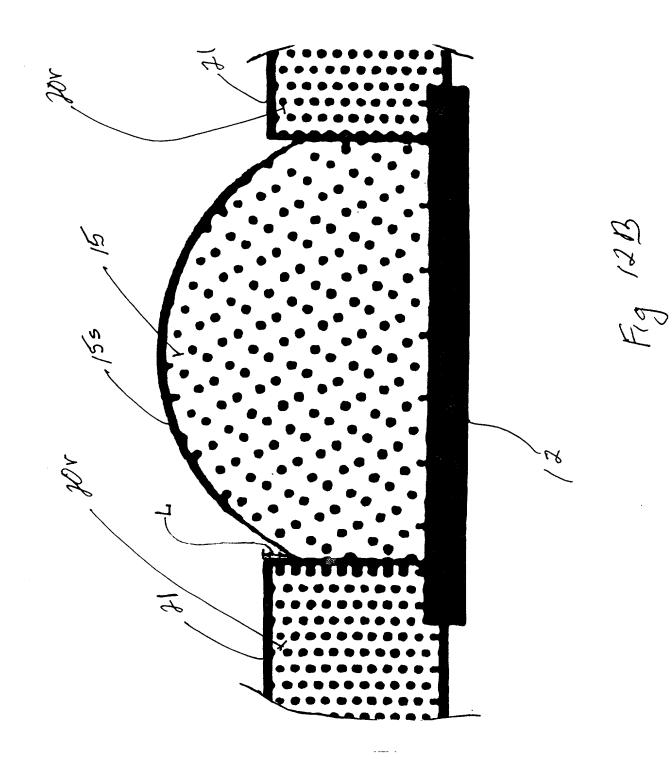
Deposit first kind of solder paste

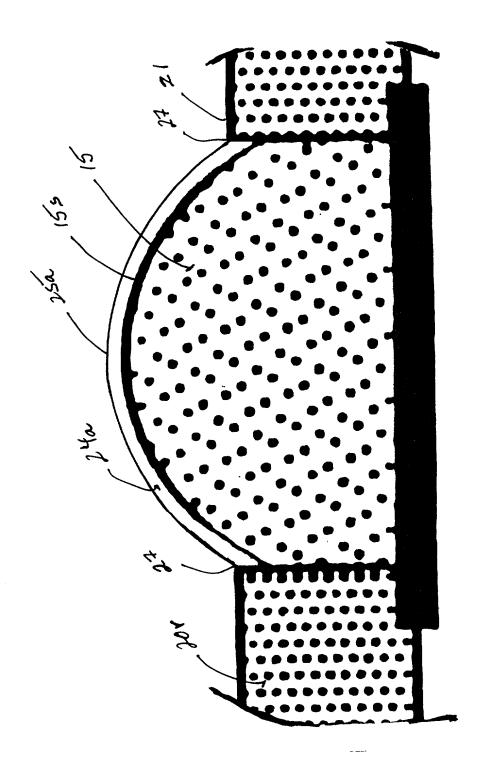
Fig 11



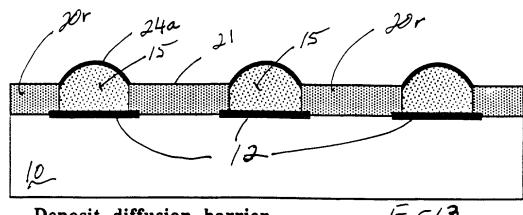
Reflow wafer to form solder bump Clean flux residual

Fir 12A



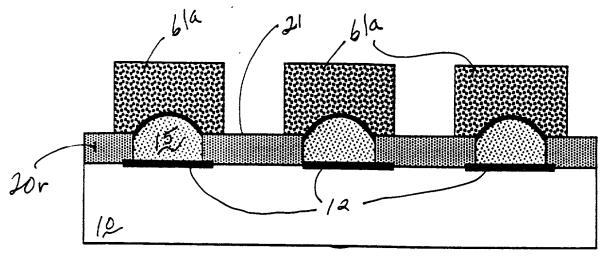


F19 126

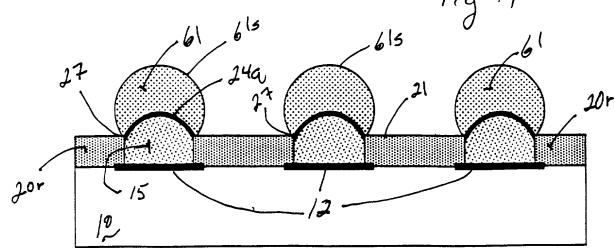


Deposit diffusion barrier





Deposit second kind of solder paste Fig 14



Reflow wafer to form solder bump Clean flux residual

Fig 15

1.15.13